



The Oblon and Maiwald firms are pleased to invite you to a *complimentary* joint international symposium on:

# U.S. and European Patent Practice – Important Aspects for Practitioners

**Thursday, 1 June 2023 at 13:00 JST, presented in person at the AP Marunouchi, Tokyo**

Please join us to learn about recent developments and current aspects of IP practice in the U.S. and Europe. Improving COVID-19 pandemic conditions makes it possible to present our annual seminar on an in-person basis only this year, however, we will still observe appropriate safety measures.

At this joint symposium, we will together examine selected current aspects of IP practice related to prosecuting applications and enforcing patents in the U.S. and in Europe. While similarities exist, applicants for U.S. and European patents need to be aware of the peculiarities and most recent developments in each system in order to achieve the best results. In particular, the symposium will address the following important topics for today's practitioners:

1. Intellectual property and e-mobility in Europe
2. Updates on claim construction and indefiniteness issues in view of the 2023 Federal Circuit decisions in *Salazar v. AT&T* and *Grace Instrument v. Chandler*
3. Start of the Unitary Patent System, a new era in Europe
4. *Ex parte* Appeals before the U.S. Patent and Trademark Office
5. Updates on extrinsic evidence and plausibility after G 2/21 in Europe
6. Enablement issues in the U.S., is the Supreme Court about to change the law?

Presenters will include: Alexander Ortlieb (Maiwald), David Longo (Oblon), Naho Fujimoto (Maiwald), Yuki Onoe (Oblon), Derk Vos (Maiwald), and Dan Pereira (Oblon).

Drinks and hors d'oeuvres will be provided at a casual reception following the symposium.

A link to register can be found [here](#).

Alternatively, you may register by e-mail to [patentconference@oblon.com](mailto:patentconference@oblon.com) or [events@maiwald.eu](mailto:events@maiwald.eu). If registering by email, please include the attendee's name(s), company, and contact information. The final registration deadline is May 26, 2023. Attendance is limited and registration will be on a first-come, first-served basis.

We look forward to welcoming you and your colleagues once again to our in-person event.

Sincerely,

Oblon, McClelland, Maier & Neustadt, L.L.P. & Maiwald GmbH

## Event Details:

Thursday, 1 June 2023, 13:00 - 17:00

AP Marunouchi  
Nissay Marunouchi Gardentower 3F,  
1-1-3 Marunouchi, Chiyoda City, Tokyo

東京都千代田区丸の内 1-1-3  
日本生命丸の内ガーデンタワー 3F

Some presentations will be held in Japanese and the others in English. Translation from English into Japanese will be provided.

## Registration:

Please register by **May 26, 2023**, through either the link provided or by email.

Please feel free to pass on this invitation on to your colleagues should you be unable to attend yourself.

## Contact:

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## Oblon, McClelland, Maier & Neustadt, L.L.P.

One of the top IP firms in the U.S., Oblon offers all aspects of IP services, including prosecution, opinions, counseling, IP transactions, litigation, and representation in post-grant proceedings. Oblon has one of the top Patent Trial and Appeal Board practice groups in the U.S. and Oblon's attorneys have developed a strong U.S. IP presence for a number of foreign and domestic companies. Many of Oblon's attorneys have advanced degrees in science or engineering, adding a high degree of technical understanding to their legal knowledge. Oblon also maintains strong connections with people in the neighboring U.S. Patent and Trademark Office, and has hired several former U.S. Patent Examiners and Administrative Patent Judges to represent its clients in patent matters before the Office.

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## Maiwald GmbH

Maiwald, one of the top IP firms in Germany, covers the full spectrum of IP-related matters. We draft and file patent and trademark applications and defend and enforce our clients' intellectual property rights in Germany, Europe, and throughout the world. Our highly specialized interdisciplinary teams of technically qualified patent attorneys and attorneys-at-law provide combined expertise across a wide range of disciplines: life sciences, chemistry, and physics; mechanical, electrical, electronic, and aeronautic engineering; communication technologies; infringement litigation, trademark, design, contract, and copyright law. Maiwald's fresh approach opens up new perspectives, and delivers customized solutions that safeguard our clients' IP rights in order to promote the success of their businesses.

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## Program – June 1, 2023

Welcome address (13:00~13:15)

Session 1 (13:15~14:20)

- Intellectual property and e-mobility in Europe (Alexander Ortlieb)
- Updates on claim construction and indefiniteness issues in view of the 2023 Federal Circuit decisions in *Salazar v. AT&T* and *Grace Instrument v. Chandler* (David Longo)

Break (14:20~14:35)

Session 2 (14:35~15:35)

- Start of the Unitary Patent System, a new era in Europe (Naho Fujimoto)
- *Ex parte* Appeals before the U.S. Patent and Trademark Office (Yuki Onoe)

Break (15:35~15:50)

Session 3 (15:50~16:50)

- Updates on extrinsic evidence and plausibility after G 2/21 in Europe (Derk Vos)
- Updates on enablement issues in the U.S., is the Supreme Court about to change the law? (Dan Pereira)

Q & A (16:50~17:00)

Reception & Refreshments (17:10~19:00)